

## CORRECTIONS

**Rob G. H. Lammertink, Mark A. Hempenius, G. Julius Vancso,\* Kwanwoo Shin, Miriam H. Rafailovich, and Jonathan Sokolov:** Morphology and Surface Relief Structures of Asymmetric Poly(styrene-*block*-ferrocenylsilane) Thin Films. Volume 34, Number 4, February 13, 2001, pp 942–950.

The Acknowledgement was inadvertently omitted from this paper. It is as follows.

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**Osman Rathore and Dotsevi Y. Sogah\*:** Nanostructure Formation through  $\beta$ -Sheet Self-Assembly in Silk-Based Materials. Volume 34, Number 5, February 27, 2001, pp 1477–1486.

The captions for Figures 3 and 5 in the above paper have been accidentally transposed. The captions should read as follows:

**Figure 3.** Powder X-ray diffraction of polymer **P2**.

**Figure 5.** Solid-state FTIR of **5** (KBr,  $2.0\text{ cm}^{-1}$  resolution, room temperature): (a) resolution-enhanced; (b) second-derivative. [Key:  $\text{ap}\beta$ , antiparallel;  $r$ , random coil;  $\text{non-}\beta$ , non- $\beta$ -sheet conformations.]

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